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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

JAN RAEBIGER
HEIKO WAGNER
UWE SCHULZE
ROLF SELTMANN

Examiner: Alan A. Mathews

Group Art Unit: 2851

Att'y Docket: 2000.108200/DE0353

Customer No.: 23720

Serial No.: 10/625,451

Filed: July 23, 2003

For: METHOD AND SYSTEM FOR
IMPROVING EXPOSURE
UNIFORMITY IN A STEP AND
REPEAT PROCESS

RESPONSE TO FINAL OFFICE ACTION DATED JULY 14, 2005

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

CERTIFICATE OF MAILING
37 C.F.R. 1.8

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date below:

September 7, 2005
Date

Mary Paul
Signature

This paper is submitted in response to the Final Office Action dated July 14, 2005, for which the three-month date for response is October 14, 2005.

No fees are believed to be due in connection with the present paper. However, should any fees be required under 37 C.F.R. §§ 1.16 to 1.21, the Director is authorized to deduct such fees from Advanced Micro Devices, Inc. Deposit Account No. 01-0365/DE0353. In the event the monies in that account are insufficient, the Director is authorized to withdraw funds from Williams, Morgan & Amerson, P.C. Deposit Account No. 50-0786/2000.108200.

Reconsideration of the application in view of the following amendments and remarks is respectfully requested.